

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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Title of Invention	METHOD OF FORMING STRAINED SI/SIGE ON INSULATOR WITH SILICON GERMANIUM BUFFER
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Application Number :

Confirmation Number:

First Named Applicant: Huajie Chen

Attorney Docket Number: FIS920030381US1

Art Unit:

Examiner:

Search string: (6603156 or 6524935).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6603156	2003-08-05	Rim			
	2	6524935	2003-02-25	Canaperi, et al.			

Signature

Examiner Name	Date